

L Number	Hits	Search Text	DB	Time stamp
1	206	((clean\$3 purg\$3) adj3 chamber) and (((purg\$3 clean\$3) adj3 (argon)) and (cvd "chemical vapor"))	USPAT; US-PGPUB; EPO; JPO	2004/07/07 13:52
-	219	"cvd apparatus".clm.	USPAT	2004/07/06 10:19
-	174	"cvd apparatus".clm. and gas.clm.	USPAT	2004/07/06 09:55
-	1	6436353.pn.	USPAT	2004/07/06 09:50
-	2	("6197699" "4847512").pn.	USPAT	2004/07/06 09:51
-	153142	438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO	2004/07/06 09:56
-	2606	438/\$.ccls. and (purg\$3)	USPAT; US-PGPUB; EPO; JPO	2004/07/06 09:57
-	1737	(438/\$.ccls. and (purg\$3)) and (h2 he hydrogen helium)	USPAT; US-PGPUB; EPO; JPO	2004/07/06 09:57
-	1282	((438/\$.ccls. and (purg\$3)) and (h2 he hydrogen helium)) and (cvd "chemical vapor")	USPAT; US-PGPUB; EPO; JPO	2004/07/06 10:04
-	1	6491758.pn.	USPAT	2004/07/06 10:20
-	75	"purging treatment"	USPAT; US-PGPUB; EPO; JPO	2004/07/06 10:20
-	325	"purging method"	USPAT; US-PGPUB; EPO; JPO	2004/07/06 10:21
-	2691	method adj3 purg\$3	USPAT; US-PGPUB; EPO; JPO	2004/07/06 10:21
-	2942	"purging treatment" "purging method" (method adj3 purg\$3)	USPAT; US-PGPUB; EPO; JPO	2004/07/06 10:21
-	327	("purging treatment" "purging method" (method adj3 purg\$3)) and (cvd "chemical vapor")	USPAT; US-PGPUB; EPO; JPO	2004/07/06 15:33
-	5843	(purg\$3 clean\$3) adj3 (hydrogen helium)	USPAT; US-PGPUB; EPO; JPO	2004/07/06 10:31
-	1090	((purg\$3 clean\$3) adj3 (hydrogen helium)) and (cvd "chemical vapor")	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:02
-	1510684	(clean\$3 purg\$3) with3 chamber	USPAT; US-PGPUB; EPO; JPO	2004/07/06 10:32
-	16132	(clean\$3 purg\$3) adj3 chamber	USPAT; US-PGPUB; EPO; JPO	2004/07/06 10:33
-	312	((clean\$3 purg\$3) adj3 chamber) and (((purg\$3 clean\$3) adj3 (hydrogen helium)) and (cvd "chemical vapor"))	USPAT; US-PGPUB; EPO; JPO	2004/07/07 13:52
-	1379	"moisture meter"	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:02
-	29	"moisture meter" and (cvd "chemical vapor")	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:03
-	28	("moisture meter" and (cvd "chemical vapor")) and (pump\$3 clean\$3 condition\$3)	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:05
-	18	("moisture meter" and (cvd "chemical vapor")) and (pump\$3 clean\$3 conditioning)	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:12
-	1748	438/5.ccls. 438/12.ccls. 438/14.ccls.	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:13
-	1	"corrosive gas treatment" and (438/5.ccls. 438/12.ccls. 438/14.ccls.)	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:12
-	6	"corrosive gas treatment"	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:12

-	519	(438/5.ccls. 438/12.ccls. 438/14.ccls.) and (moisture moist\$3 wet water)	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:15
-	1	(438/5.ccls. 438/12.ccls. 438/14.ccls.) and ("moisture meter")	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:20
-	4560	427/255.28.ccls. 427/250.ccls. 427/569.ccls.	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:20
-	1	(427/255.28.ccls. 427/250.ccls. 427/569.ccls.) and "moisture meter"	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:21
-	225	(427/255.28.ccls. 427/250.ccls. 427/569.ccls.) and ("water vapor")	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:37
-	17	(438/5.ccls. 438/12.ccls. 438/14.ccls.) and ("water vapor")	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:39
-	1810	118/724.ccls.	USPAT; US-PGPUB; EPO; JPO	2004/07/06 11:39